L Number	Hits	Conrab Bout	L D.D.	m:
1	1 1		DB	Time stamp
1 -	1 1	("5118485").PN.	USPAT;	2003/12/01 11:19
2			US-PGPUB	
4	93025	CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:20
			US-PGPUB	
3	96259	\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:54
1.	1		US-PGPUB	
4	2		USPAT;	2003/12/01 11:22
-) same water with recycle	US-PGPUB	
5	26	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:24
) and water with recycle	US-PGPUB	
6	16		USPAT;	2003/12/01 11:32
	!) and direct\$3 with recycle	US-PGPUB	i i
7	16	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:32
) with recycle	US-PGPUB	1
8	52	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:36
) with recycl\$4	US-PGPUB	
9	1	("4468283").PN.	USPAT;	2003/12/01 11:43
			US-PGPUB	2000, 12, 01 11110
10	0	(CVD (chemical adj vapor adj deposition))	USOCR	2003/12/01 11:44
1		with recycl\$4		
11	12		USOCR	2003/12/01 11:47
		deposition)) and recycl\$4		
12	128	vapor with direct\$5 with recycle	USOCR	2003/12/01 11:47
13	128	vapor with direct\$5 with recycle	USOCR	2003/12/01 11:47
14	154	vapor with direct\$5 with recycle	USPAT;	2003/12/01 11:48
	104	vapor with directly with recycle	US-PGPUB	2003/12/01 11:48
15	69	vapor with directly with recycle		2002/12/01 12:44
1-5	. 03	vapor with directly with recycle	USPAT;	2003/12/01 13:44
16	123	(630VD (abamina) add	US-PGPUB	0000/10/01 11 5.
1 - 0	123	(\$3CVD (chemical adj vapor adj deposition)) and recycl\$5 with water	USPAT;	2003/12/01 11:54
1) and recyclas with water	US-PGPUB	
17	1683	/63CVD (=>===================================		0000 (40 (04 44 55
1.7	1003	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 11:55
) and recycl\$5	US-PGPUB	
18	31	(42000 (-2		
1 10	31	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:42
i) and recycl\$5 with directly	US-PGPUB	
19	15654	/620VD (=h===================================		
1 2	13034	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:21
20	196) and (dipole polar\$7)	US-PGPUB	
20	190	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:21
21	13) with (dipole polar\$7)	US-PGPUB	0000/00/05
41	13	((\$3CVD (chemical adj vapor adj	USPAT;	2003/12/01 13:42
	0	deposition)	US-PGPUB	1
) and recycl\$5 with directly		I
1 22	<u> </u>) and permeate		1
22	8	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:47
100	9) with raw with recycl\$5	US-PGPUB	
23	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 13:48
1) with unseparated with recycl\$5	US-PGPUB	
24	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:00
1.5) and unseparated with recycl\$5	US-PGPUB	
25	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:00
1) and untainted with recycl\$5	US-PGPUB	
26	0	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:00
	i) and unprocess\$4 with recycl\$5	US-PGPUB	
27	17	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:15
1) and outlet with inlet with direct\$3	US-PGPUB	
1		near2 (connect\$6)		
28	2	(\$3CVD (chemical adj vapor adj deposition)	USPAT;	2003/12/01 14:15
	İ) and outlet with inlet with direct\$3	US-PGPUB	
	ļ	near2 (coup1\$6)		
				l